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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
10/679,004	10/02/2003	Michael J. Berman	03-0962/LSI1P232	8894		
7:	590 09/28/2004	EXAM	EXAMINER			
LSI Logic Corporation 1551 McCarthy Boulevard			TOLEDO, FE	TOLEDO, FERNANDO L		
Milpitas, CA			ART UNIT	PAPER NUMBER		
			2823			
			DATE MAILED: 09/28/2004	DATE MAILED: 09/28/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

_		Application	No.	Applicant(s)				
Office Action Summary								
		Examiner		BERMAN ET AL.				
	<b>,</b>	Fernando L	Tolodo	Art Unit	لهم			
	The MAILING DATE of this communication				iress			
Period fo		<b>,-,</b>						
THE I - Exter after - If the - If NO - Failu	ORTENED STATUTORY PERIOD FOR REMAILING DATE OF THIS COMMUNICATION Is sions of time may be available under the provisions of 37 CF SIX (6) MONTHS from the mailing date of this communication period for reply specified above is less than thirty (30) days, a period for reply is specified above, the maximum statutory pere to reply within the set or extended period for reply will, by seply received by the Office later than three months after the red patent term adjustment. See 37 CFR 1.704(b).	ON. R 1.136(a). In no even n. a reply within the statute eriod will apply and will ttatute, cause the applic	t, however, may a reply be time ory minimum of thirty (30) days expire SIX (6) MONTHS from ation to become ABANDONE	nely filed s will be considered timely. the mailing date of this con O (35 U.S.C. § 133).	rmunication.			
Status								
1)	Responsive to communication(s) filed on <u>0</u>	02 October 2003						
•		This action is no						
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Dispositi	on of Claims							
5)□ 6)⊠ 7)⊠ 8)□	4)  Claim(s) 1-21 is/are pending in the application.  4a) Of the above claim(s) is/are withdrawn from consideration.  5)  Claim(s) is/are allowed.  6)  Claim(s) 1-3,5-9,12,13 and 16-21 is/are rejected.  7)  Claim(s) 4,10,11,14 and 15 is/are objected to.  8)  Claim(s) are subject to restriction and/or election requirement.							
_	on Papers							
10)⊠	The specification is objected to by the Exar The drawing(s) filed on <u>02 October 2003</u> is, Applicant may not request that any objection to Replacement drawing sheet(s) including the co The oath or declaration is objected to by the	/are: a)⊠ accept the drawing(s) be the drawing(s) be the traction is required	held in abeyance. Seed if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFF	R 1.121(d).			
Priority u	ınder 35 U.S.C. § 119							
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>								
Attachmen	t(s)							
1) Notice 2) Notice 3) Inform	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948 nation Disclosure Statement(s) (PTO-1449 or PTO/SE r No(s)/Mail Date	B/08)	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ate	.152)			

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#### **DETAILED ACTION**

### Claim Objections

1. Claim 13 is objected to as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. Claim 13 recites, "to remove a majority of the dielectric matrix". The word "majority" is indefinite since it leaves to speculation what majority means. Is more than half majority; is it two-thirds or three-fourths a majority? What constitute a majority?

2. Claims 4, 10, 11, 14 and 15 objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

#### Claim Rejections - 35 USC § 102

(e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.

3. Claims 18 – 21 are rejected under 35 U.S.C. 102(e) as being anticipated by Sun et al. (US Patent Application Publication US 2003/0047541 A1).

In re claim 18, Sun, in the US Patent Application Publication US 2003/0047541 A1; figures 1 – 2B and related text, discloses a low-k dielectric film; and whisker reinforcement distributed throughout the film (Paragraph 0033).

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4. In re claim 19, Sun discloses wherein the whisker reinforcements are selected from the group consisting of SiC, Si<sub>3</sub>N<sub>4</sub>, oxides, polymers, and diamond structured materials (Paragraph 0033).

5. In re claim 20, Sun discloses wherein the whiskers occupy a volume in the matrix in the range of 0.1 to 10% (Paragraph 0033).

## Claim Rejections - 35 USC § 103

- 6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 7. Claims 1 3, 5 9, 13, 16 and 17 are rejected under 35 U.S.C. 103(a) as being unpatentable over Woo et al. (U. S. Patent 6,531,777 B1) in view of Sun et al.

In re claim 1, Woo, in the U. S. Patent 6,531,777 B1; figures 1-5 and related text, discloses forming a dielectric matrix 34 on a semiconductor wafer 30.

Woo does not disclose distributing a reinforcing material including one of fibers and nanostructure whiskers throughout the dielectric matrix film to form the dielectric composite film.

However, Sun discloses distributing a reinforcing material including one of fibers and nanostructure whiskers throughout the dielectric matrix film to form the dielectric composite film to reinforce the low-k dielectric film (Paragraph 0033).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to distribute fibers or nanostructure whiskers throughout the dielectric matrix of Woo, since, as taught by Sun, the whiskers or fibers help reinforce the dielectric matrix.

- 8. In re claim 2, Woo in view of Sun discloses wherein the reinforcing material comprises nanostructure whiskers (Paragraph 0033 of Sun).
- 9. In re claim 3, Woo discloses wherein the dielectric matrix film is selected from the group consisting of  $SiO_2$  and low-k dielectric layers (Column 3, Lines 7 10).
- 10. In re claim 5, Woo in view of Sun discloses wherein the reinforcing material comprises an insulating ceramic material (Paragraph 0033 of Sun).
- 11. In re claim 6, Woo in view of Sun discloses wherein the whiskers are rod-shaped and have a length in the range from 5 to 20 nm (Paragraph 0033 of Sun).
- 12. In re claim 7, Woo in view of Sun discloses wherein the whiskers have aspect ratios in the range of 5:1 to 300:1 (Paragraph 0033 of Sun).
- 13. In re claim 8, Woo in view of Sun discloses wherein the whiskers are randomly oriented (Paragraph 0033 of Sun).
- 14. In re claim 9, Woo in view of Sun discloses wherein the volume of the whiskers in relation to the volume of the matrix material lies in the range from 0.1 to 10% (Paragraph 0033 of Sun).
- 15. In re claim 13, Woo discloses further comprising etching the dielectric matrix film to remove a majority of the dielectric film matrix (Column 3, Lines 15-20).
- 16. In re claim 16, Woo discloses further comprising forming an inlaid conductive layer in the low-composite layer (Figure 4).

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- 17. In re claim 17, Woo discloses wherein the inlaid copper layer is a copper dual-damascene interconnect structure (Column 2, Lines 60 64).
- 18. Claim 12 is rejected under 35 U.S.C. 103(a) as being unpatentable over Woo in view of Sun as applied to claims 1 3, 5 9, 13, 16 and 17 above, and further in view of Grill et al. (U. S. Patent 6,030,904).

Woo in view of Sun does not teach further comprising heating the dielectric matrix film to vaporize volatile components. However, Grill, in the U. S. Patent 6,030,904; figures 1A - 2F and related text, discloses annealing dielectric layers such as BCB to stabilize the low-k dielectric layer (Column 2, Lines 54 - 63).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to anneal the low-k dielectric layer of Woo in view of Sun, since, as taught by Grill, it annealing the low-k dielectric layer stabilizes the low-k dielectric layer.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Fernando L. Toledo whose telephone number is 571-272-1867. The examiner can normally be reached on Mon-Thu 7am to 5:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

George Fourson
Primary Examiner
Art Unit 2823

FToledo

27 September 2004